

35 U.S. PTO
09/785445
02/20/01

Subclass	Class	ISSUE CLASSIFICATION

U.S. UTILITY Patent Application

O.I.P.E.

PATENT DATE

SCANNED

9/19

Q.A.

9/19

APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINER
09/785445	100-1000	257	782	2811	H. VU

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TITLE
Single damascene integration scheme for preventing copper contamination of dielectric layer

PTO-2040
12/98

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ISSUING CLASSIFICATION

ORIGINAL		CROSS REFERENCE(S)			
CLASS	SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)		
INTERNATIONAL CLASSIFICATION					
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TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	(Assistant Examiner) _____ (Date) _____			NOTICE OF ALLOWANCE MAILED	
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